

Abstract

Described is an embossing station (10) for an embossing apparatus which is provided for transferring a transfer layer (12) of an embossing film (14) on to an element to be embossed upon, in particular a flat element (16) to be embossed upon which is stable in respect of shape. The embossing station (10) has two support rollers (18) which are spaced from each other and which are in mutually axis-parallel relationship and at least one deflection roller (22) which is spaced from the support rollers and which is in axis-parallel relationship with the support rollers (18). An embossing belt (24) is deflected around the support rollers (18) and the at least one deflection roller (22). Provided between the two support rollers (18) is a support body (32) which supports the embossing belt (24) and which has a sliding surface (34) which is in the tangential plane (36) connecting the two support rollers (18) together.

(Figure 1)